Se	arch	Notes



Application/Control No.	Applicant(s)/Patent under Reexamination	
10/501,228	ONOI ET AL.	
Examiner	Art Unit	
Ling-Siu Choi	1713	

SEARCHED					
Class	Subclass	Date	Examiner		
525	374	4/28/2005	LSC		
	375				
	377				

INTERFERENCE SEARCHED						
. Class	Subclass	Date	Examiner			
, , , , , ,						
		-				

SEARCH NOTES (INCLUDING SEARCH STRATEGY)					
	DATE	EXMR			
West	4/28/2005	LSC			
stable free radical- carbon radical- TEMPO or nitroxide					